

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Washio et al.  
Appl. No. : 10/560,155  
Filed : December 9, 2005  
For : DEVELOPER COMPOSITION  
FOR RESISTS AND METHOD  
FOR FORMATION OF RESIST  
PATTERN  
Examiner : Le, Hoa Van  
Group Art Unit : 1752

AMENDMENT AND RESPONSE TO OFFICE ACTION**Mail Stop Amendment**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **September 25, 2006**, Applicants respectfully request consideration of the following amendments and remarks:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 3 of this paper.